

DSW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Aaron O. Vanderpool et al.

§ Art Unit: 2891

Serial No.: 10/789,851

§ Examiner: Asok K. Sarkar

Filed: February 26, 2004

§ Atty Docket: ITL.1078US
P18386

For: Implanting Carbon to
Form P-Type Source
Drain Extensions

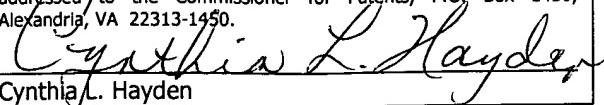
§ Assignee: Intel Corporation

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

In response to the restriction requirement mailed July 15, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: <u>July 21, 2005</u>
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden